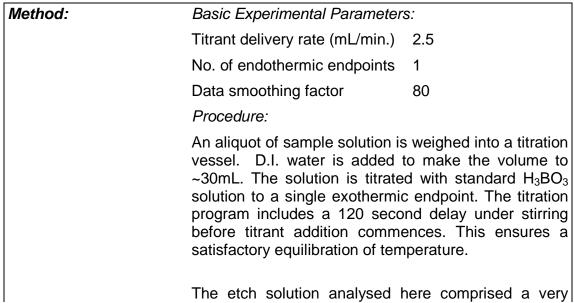
Thermo. Titr. Application Note No. H-098

Title:	Determination of Hydrofluoric Acid in Silicon Etch solutions
Scope:	Determination of fluoride in industrial solutions such as acid etching mixtures.
Principle:	Acidic solutions of fluoride react exothermically with boric acid according to the equations:
	$H_3BO_3 + 3H^+ + 3F^- \leftrightarrow HBF_3(OH) + 2H_2O \tag{1}$
	$\underline{HBF_{3}(OH) + H^{+} + F^{-} \leftrightarrow HBF_{4} + H_{2}O} (slow) \tag{2}$
	${ m H_3BO_3} + 4{ m H}^+ + 4{ m F}^- \leftrightarrow { m HBF_4} + 3{ m H_2O}$ When fluoride is the analyte (and boric acid the titrant), only reaction (1) is observed, and hence 3 mol of fluoride reacts with 1 mol of boric acid.
	The titrations are carried out in plastic titration vessels (e.g., 6.1450.210 PFA titration vessel, 10-90mL), as acidic fluoride solutions react with glass vessels. A fluoride-resistant 6.9011.040 Thermoprobe is also used in this determination.
Reagents:	0.7 mol/L boric acid solution



high proportion of nitric acid with a small amount of hydrofluoric acid. An average sample mass of approximately 20g was employed.

Results: Replicate analysis of a used etch solution from etching of

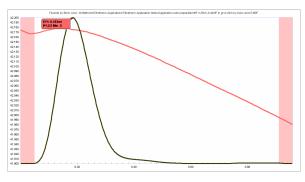
silicon substrate:

% HF = 0.049, 0.047, 0.047, 0.046

Calculation:

 $\%HF = \frac{((titre, mL - blank, mL) \times M H_3BO_3 \times FW HF \times 3 \times 100)}{(sample vol, mL \times 1000)}$





Legend:

Red = solution temperature curve

Black = second derivative curve

Blank determination

Note: the less than ideal linearity is a function of the extremely small titration volumes (~0.14 – 0.24mL) experienced when analyzing the sample. However, the fact that the titration volume was seen to vary with sample mass shows the validity of the method in analyzing small amounts of HF

